# NCCAVS Junction Technology Group: Dec 11, 2025

Northern California Chapter AVS
Junction Technology Group

Recent Conference Presentations on Junction Technologies

**NEW MEETING DATE: DECEMBER 11, 2025** 

New Meeting Date: December 11, 2025

New Meeting Time: 9:00 AM to 11:30 PM (Pacific Time) Check Your Time Zone

#### Location:

Eurofins EAG Room: Library 810 Kifer Road Sunnyvale, CA 94086



#### Co-Chairs

Michael Current, Current Scientific Susan Felch, Susan Felch Consulting John O. Borland, J.O.B. Technologies



#### **Meeting Sponsor:**

### **UC Components**

## **Custom Solutions** for Your Industry

Our modern 16,000-square-foot manufacturing facility in Morgan Hill, California, supplies:

- Start-ups
- OEMs.
- Government Labs.
- Universities,
- End-users,
- Various other facilities worldwide,
- and the distribution networks that supply them.

With a laser-targeted focus on genuine customer-centered service, UC meets the needs of small and large customers alike.

Learn more at www.uccomponents.com.

# Ion Implantation Technology News: Conferences

IWJT25: Uji (Kyoto), Japan

Jun 4-6, 2025

#### Lead chair:

Satoshi Shibata (Panasonic)



John

### JTG Agenda: Dec 11, 2028

9:00 - 9:40 AM "Metal—Semiconductor Contacts: From Silicide Insights to Next-Generation Material Devices", Philippe Rodriguez, CEA-LETI

9:40 - 10:20 AM "Gas/Vapor Phase Epi (VPE), Liquid Phase Epi (LPE) & Solid Phase Epi (SPE) Doping Methods in Si, SiGe and Ge: A Historical Review", John Ogawa Borland, J.O.B. Technologies

10:20 - 10:35 AM Break/Refreshments (coffee & pastries), Sponsored by UC Components

10:35 - 11:15 AM "Ion Channeling in Si and SiC: A Historical Review", Michael I. Current, Current Scientific

**11:15 - 11:30 AM** Conference information on IIT 2026 (in Villach, Austria) & IWJT 2026 (in Grenoble, France), **Michael Current** 

**NOTE:** Presentations will be posted on the JTG Proceedings webpage within 2 weeks following the meeting with permission of presenters.

# IIT26- Villach, Austria: Sept 20-24, 2026

IIT Implant & Annealing School: Sept 17-19, 2026



Dear Colleagues,

We would like to cordially invite you to attend and contribute to THE 25TH INTERNATIONAL CONFERENCE ON ION IMPLANTATION AND ANNEALING TECHNOLOGY (IIT 2026),

which will take place in Villach, Austria, in September 2026:

- September 17–19, 2026 IIT School at Infineon Villach
- September 20-24, 2026 IIT Conference at the Congress Centre Villach

This jubilee 25th edition of the International Conference on Ion Implantation and Annealing Technology (IIT) marks an important milestone, accompanied by an updated conference name to more accurately reflect the growing importance of post-implant thermal treatment in ion implantation processes.

General chair:
Werner Schustereder
(Senior Principal Ion Implantation,
Infineon Technologies, Austria)



Web: https://www.iitvillach2026.com/

# IWJT26- Grenoble, France: Sept 28-29, 2026



23<sup>rd</sup> International Workshop on Junction Technology

September 28-29, 2026 Grenoble - France

As the premier global forum for semiconductor junction-formation technology, IWJT attracts leading researchers and engineers from Asia, Europe, and the U.S. each year. For the first time the workshop will be held outside Japan and China since its founding in 2000.

Join participants from industry, academia, and national laboratories to share cutting-edge breakthroughs and forge new collaborations!



General Chair: Philippe Rodriguez (CEA-Leti)
Program Chair: Anabela Veloso (imec)
Executive Chair: Yoshiaki Kikuchi (Sony)

Contact: iwit2026@gmail.com



**General chair: Philippe Rodriquez** (CEA-Leti)



**Contact:** 

iwjt2025@gmail.com

Web: TBD